



Xerox Corporation has an internship opportunity available at Webster, NY site for an undergraduate student interested in the research and development of advanced photoconductive materials during the summer of 2012 (starting from 5/21/2012). This individual will be responsible for the preparation of organic, inorganic, and polymeric photoconductive materials, formulation of photoconductive devices, including dispersion preparation, and analytical characterization. As a member of a development team, the individual will be involved in the planning and execution of experiments to design, synthesize, and evaluate new materials for applications to xerography. Candidates must enjoy hands-on bench work and possesses excellent laboratory skills.

**Qualifications:**

- Student must be pursuing a Bachelor's degree in Chemistry, Chemical Engineering, Materials/Polymer Science or the like with a GPA>3.0.
- Laboratory experience necessary; exposure to organic and/or polymer science would be noteworthy.
- Good problem solving skills and ability to provide sound technical decisions.
- Good communication skills, both written and verbal, are essential.
- Must be a strong team player.

Interested candidates may forward their resume to:

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